

In re application of: Youichi TEI et al.

Art Unit: Not Yet Assigned

Appl. No: 10/706,987

Examiner: Not Yet Assigned

Confirmation No: Not Yet Assigned

Atty. Docket No: 32307-192751

Filed: November 14, 2003

Customer No:

For: THERMOPLASTIC

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ALLYLOXYMETHYLSTYRENE-

PATENT TRADEMARK OFFICE

BASED RESIN

Supplemental Second Information Disclosure Statement

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is an Information Disclosure Statement submitted under 37 C.F.R. § 1.97 within the time specified under 37 C.F.R. § 1.97(b).

This Information Disclosuré Statement supplements the second Information

Disclosure Statement filed February 2, 2004 by providing translations of the four submitted documents.

In order to comply with the duty of disclosure under 37 C.F.R. § 1.56, the U.S. Patent and Trademark Office is notified of the documents which are listed on the attached Form PTO/SB/04A and which the Examiner may deem relevant to patentability of the claims of the above-identified application. A copy of each of the listed documents are enclosed and translation of each documents is submitted herewith.

Applicant(s): Youichi TEI et al.

Application No.: 10/706,987

The present Information Disclosure Statement is being filed before the mailing date of

the first Office Action on the merits, and therefore no Statement Under 37 C.F.R. § 1.97(e) or

fee under 37 C.F.R. § 1.17(p) is required.

In view of the above, no further translation or statement of relevance is required, and

as all requirements of 37 C.F.R. § 1.97 and all official guidelines pertaining to Information

Disclosure Statements have been complied with, and it is therefore respectfully requested that

the Examiner consider the documents and make them of record.

Please charge any necessary fee or credit any overpayment in connection with this

Information Disclosure Statement to Deposit Account No. 22-0261.

Respectfully submitted,

Date: Fohruary 12, 2004

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Substitute for form 1449A/PTO	Complete if Known		
INCORMATION DISCLOSURE	Application Number	10/706,987	
INFORMATION DISCLOSURE	Filing Date	November 14, 2003	
STATEMENT BY APPLICANT	First Named Inventor	Youichi TEI et al.	
ALPE	Group Art Unit	Not Yet Assigned	
(use as many sheets as necessary)	Examiner Name	Not Yet Assigned	
Sheet 1 3\ of 1	Attorney Docket Number	32307-192751	

OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS					
RADIExaminer nitials *	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²		
	Ai	H. LEE et al., "Radical Cyclopolymerization of Bis (2-phenylallyl)ether", Page 196, November 17, 2002.	1		
	A2	Hiroki NAKAI et al., "Radical cyclopolymerization of α-allyloxymethylstyrene", Page 197, November 17, 2002.	4		
	А3	Hyun-jin LEE et al., "Radical Cyclopolymerization of Bis(2-phenylally)ether-Synthesis and Properties of Highly Cyclized Polymers Obtained Using a Functional Group with Low Homoploymerizability", Page 164, May 28, 2003.	4		
	A4	Hyun-Jin LEE et al., "Cyclopolymerization of a 1,6-Diene with 2-Phenylallyloxy Group and Properties of the Polymers Derived Therefrom", Page 1220, September 24, 2003.	1		

Examiner	Date	
Signature	Considered	
Colginataro	Considered	

SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.





EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² Applicant is to place a check mark here if English language Translation is attached.